

<b>Notice of References Cited</b>	Application/Control No.	Applicant(s)/Patent Under Reexamination	
	09/838,513	CHEN ET AL.	
	Examiner	Art Unit	Page 1 of 1
	Julio J. Maldonado	2823	

**U.S. PATENT DOCUMENTS**

*	Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
A	US-5,937,325	08-1999	Ishida	438/655
B	US-			
C	US-			
D	US-			
E	US-			
F	US-			
G	US-			
H	US-			
I	US-			
J	US-			
K	US-			
L	US-			
M	US-			

**FOREIGN PATENT DOCUMENTS**

*	Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
N					
O					
P					
Q					
R					
S					
T					

**NON-PATENT DOCUMENTS**

*	Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
U	Mouroux, Aliette; The Reactive Formation of TiSi2 in the Presence of Refractory Metals (from V to W), Royal Institute of Technology, Department of Electronics, Stockholm 1,999, pages
V	
W	
X	

\*A copy of this reference is not being furnished with this Office action (See MPEP § 707.05(a))  
 Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.